ORIGINAL PAPER

An overview of halogen bonding

Peter Politzer • Pat Lane • Monica C. Concha • Yuguang Ma • Jane S. Murray

Received: 30 September 2005 / Accepted: 9 August 2006 / Published online: 30 September 2006 Springer-Verlag 2006

Abstract Halogen bonding (XB) is a type of noncovalent interaction between a halogen atom X in one molecule and a negative site in another. X can be chlorine, bromine or iodine. The strength of the interaction increases in the order Cl<Br<I. After a brief review of experimental evidence relating to halogen bonding, we present an explanation for its occurrence in terms of a region of positive electrostatic potential that is present on the outermost portions of some covalently-bonded halogen atoms. The existence and magnitude of this positive region, which we call the σ -hole, depends upon the relative electron-attracting powers of X and the remainder of its molecule, as well as the degree of sp hybridization of the s unshared electrons of X. The high electronegativity of fluorine and its tendency to undergo significant sp hybridization account for its failure to halogen bond. Some computed XB interaction energies are presented and discussed. Mention is also made of the importance of halogen bonding in biological systems and processes, and in crystal engineering.

Keywords Halogen bonding · Noncovalent interactions · Molecular electrostatic potentials

Proceedings of "Modeling Interactions in Biomolecules II", Prague, September 5th–9th, 2005.

P. Politzer (⊠) · P. Lane · M. C. Concha · J. S. Murray Department of Chemistry, University of New Orleans, New Orleans, LA 70148, USA e-mail: ppolitze@uno.edu

Y. Ma

Department of Chemistry, Wake Forest University, Winston-Salem, NC 27106, USA

What is halogen bonding?

Halogen bonding (XB) is a noncovalent interaction that is in some ways analogous to hydrogen bonding (HB). In the latter, a hydrogen atom is shared between an atom, group or molecule that "donates" and another that "accepts" it. In halogen bonding, it is a halogen atom X that is shared between a donor D and an acceptor A. Thus the two types of interaction can be depicted by:

$$HB:D-H---A \qquad XB:\ D-X---A$$

X can be chlorine, bromine or iodine, but not, to our knowledge, fluorine. The angle D-X-A is close to 180°.

In HB and also in XB, both the donor and especially the acceptor tend to be electronegative, or electron-withdrawing. The acceptor is often a Lewis base, i.e. it has an available pair of electrons. Since hydrogens usually are considered to have partial positive charges, it is understandable that they interact attractively with electronegative atoms. But why would halogen atoms, which are generally viewed as being negative, undergo such interactions? This question shall be addressed in this paper.

Background

It has been known since the nineteenth century that Cl_2 , Br_2 and I_2 can form complexes with Lewis bases such as ammonia and methylamines [1, 2]. These were sometimes described as "charge–transfer" or "electron donor–acceptor" interactions, and Mulliken, [3] and later Flurry, [4, 5] developed theoretical formalisms for describing them. Eventually it was recognized that not only dihalogens and interhalogens but also many organic halides can form such complexes; an early review was given by Bent [6]. The analogies between such interactions and hydrogen bonding were discussed by Bent [6] and by Hassel [7]. However the first use of the term "halogen bond" that we have found was by Dumas et al. [8], in the context of experimental studies of complexes formed by CCl_4 , CBr_4 , $SiCl_4$ and $SiBr_4$ with tetrahydrofuran, tetrahydropyran, pyridine, anisole and di-*n*-butylether in organic solvents [8–10].

An important advance in understanding the noncovalent interactions of halogen atoms came through the analysis of large numbers of crystal structures from the Cambridge Structural Database, for example by Murray-Rust et al. [11-13]. They were looking for anomalously short intermolecular distances, i.e. less than the sum of the van der Waals radii of the atoms involved. Such distances were interpreted as indicating unusually strong atomic interactions. For halogens linked to carbons, certain distinct tendencies were found. Close contacts with electrophiles, such as metal ions, occurred largely at angles of 90°–120° with the C-X bond (1). With nucleophiles, however, such as oxygens and nitrogens, the angles were primarily between 160° and 180° (2). These generalizations apply for X=CI, Br and I. (When X=F, the close contacts detected were only with electrophiles.) The near-linear interactions with nucleophiles are what has come to be known as "halogen bonding".



In view of the analogies between halogen and hydrogen bonding, can the former compete and interfere with the latter? This question has been addressed by Sandorfy et al. in a series of studies of the infra-red spectra of solutions of various organic bases [14–16]. They found that the IR peak due to solute-solute intermolecular hydrogen bonding is considerably diminished by the introduction of a co-solute capable of significant halogen bonding. Di Paolo and Sandorfy concluded that [17] "...*fluorocarbons containing higher halogens can break hydrogen bonds...probably due to competitive donor–acceptor complex formation.*" They found hydrogen-bond-breaking potency to increase in the order F<Cl<Br<I.

Origins of halogen bonding

We pointed out some time ago that the basis for halogen bonding can be seen in the respective molecular electrostatic potentials [18, 19]. We shall now extend our earlier analysis, and at a higher computational level.

The electrostatic potential $V(\mathbf{r})$ that is created at a point \mathbf{r} by a molecule's nuclei and electrons is given rigorously by

$$V(\mathbf{r}) = \sum_{A} \frac{Z_{A}}{|\mathbf{R}_{A} - \mathbf{r}|} - \int \frac{\rho(\mathbf{r}')d\mathbf{r}'}{|\mathbf{r}' - \mathbf{r}|}$$
(1)

in which Z_A is the charge on nucleus A, located at \mathbf{R}_A , and $\rho(\mathbf{r})$ is the molecule's electronic density function. $V(\mathbf{r})$ is a real physical property, which can be determined experimentally [20, 21] as well as computationally. Its sign in any given region depends upon whether the positive effect of the nuclei or the negative one of the electrons is dominant there.

The electrostatic potential has been found to be an effective tool for analyzing and predicting noncovalent interactions [22–25]. For this purpose, we normally compute it on the surfaces of the molecules, and denote it by $V_{\rm S}(\mathbf{r})$. We take the surfaces to be the 0.001 electrons/bohr³ contours of the molecular electronic densities, as suggested by Bader et al. [26]. We characterize $V_{\rm S}(\mathbf{r})$ by means of several statistically-defined quantities [23–25], including its most positive and most negative values, $V_{\rm S,max}$ and $V_{\rm S,min}$.

What is particularly relevant in the present context is that hydrogen bond donating and accepting tendencies can be related quantitatively to $V_{S,max}$ and $V_{S,min}$, respectively [27].

The electrostatic potential of a neutral free atom is positive everywhere [28, 29], the contribution of the nucleus dominating those of the dispersed electrons. However when atoms interact to form a molecule, some regions of negative $V(\mathbf{r})$ and $V_{\rm S}(\mathbf{r})$ do normally develop [21, 22, 25, 30–32], particularly near the lone pairs of electronegative atoms, i.e. N, O, F, Cl, Br, etc. Thus it is customary to expect negative $V_{\rm S}(\mathbf{r})$ associated with halogen substituents, which makes it difficult to understand the occurrence of halogen bonding, in which they interact noncovalently with negative sites, such as the lone pairs of electronegative Lewis bases.

A reasonable explanation for this puzzling phenomenon came initially from a Hartree-Fock computational analysis of the molecular surface electrostatic potentials of six halogenated methanes, CH_3X and CX_4 , in which X=F, Cl, and Br [18, 19]. We have now used a density functional procedure, B3PW91/6-31G(d,p), to extend this study to a more diverse group of molecules. The surface potentials for some of them are in Figs. 1, 2, 3, 4, 5, and 6.

In CH₃F, CH₃Cl and CF₄, the halogen surfaces are negative, as anticipated. This can be seen for CH₃Cl in Fig. 1. When the halogen is bromine or iodine, however, there is a new and perhaps unexpected feature: a positive region on the outermost portion of the halogen surface, where it intersects the C–X axis. This is shown in Fig. 2 for CH₃Br. Such a positive region may also appear for chlorine



Fig. 1 The computed B3PW91/6-31G(d,p) electrostatic potential, in kcal mol⁻¹, on the 0.001 electrons/bohr³ surface of CH₃Cl. The chlorine atom is at the *right*. The color ranges are: *red*, more positive than 15; *yellow*, between 7 and 15; *green*, between 0 and 7; *blue*, between -10 and 0; *purple*, more negative than -10

when electron-withdrawing substituents are introduced into the remainder of the molecule, as in CF₃Cl (Fig. 3) and NC-C=C-Cl (Fig. 4). In the case of CF₃Br (Fig. 5), the presence of the fluorines strengthens the positive bromine potential already observed in CH₃Br. For all of these molecules, as well as several others, the most positive halogen potentials, the $V_{S,max}$, are collected in Table 1.



Fig. 2 The computed B3PW91/6-31G(d,p) electrostatic potential, in kcal mol⁻¹, on the 0.001 electrons/bohr³ surface of CH₃Br. The bromine atom is *pointing out of the page*. The color ranges are: *red*, more positive than 15; *yellow*, between 7 and 15; *green*, between 0 and 7; *blue*, between -10 and 0; *purple*, more negative than -10



Fig. 3 The computed B3PW91/6-31G(d,p) electrostatic potential, in kcal mol⁻¹, on the 0.001 electrons/bohr³ surface of CF₃Cl. The chlorine atom is at the *top*. The color ranges are: *red*, more positive than 15; *yellow*, between 7 and 15; *green*, between 0 and 7; *blue*, between -10 and 0; *purple*, more negative than -10

It is evident from Table 1 that the presence and magnitude of a positive halogen potential depends upon both the halogen and the electron-withdrawing power of the remainder of the molecule. We have never found a positive $V_{S,max}$ for fluorine, and for chlorine only if the rest of the molecule is sufficiently electron-attracting. Table 1 shows that this is not the case in HO–CH₂CH₂–Cl, but it is so when OH is replaced by NO₂. However, it should be noted that V_{S,max} is considerably less in O₂N–CH₂CH₂–Cl (Fig. 6) than in NC–C=C–Cl, even though the nitro group is certainly highly electron-attracting. This is because it can act only inductively in O₂N–CH₂CH₂–Cl, whereas the cyano in NC–C=C–Cl has both inductive and resonance possibilities:



The bromine $V_{S,max}$ are always stronger than the chlorine (Table 1), wherever comparisons can be made. The high $V_{S,max}$ of chlorine in H–C=C–Cl may be surprising. However, there is both theoretical and experimental evidence that makes this plausible [33].

It was proposed as early as 1992 [18, 19], and again more recently, [34] that these positive outer portions of

307



Fig. 4 The computed B3PW91/6-31G(d,p) electrostatic potential, in kcal mol⁻¹, on the 0.001 electrons/bohr³ surface of NC–C=C–Cl. The chlorine atom is at the *right*. The color ranges are: *red*, more positive than 15; *yellow*, between 7 and 15; *green*, between 0 and 7; *blue*, between -10 and 0; *purple*, more negative than -10

some halogen surfaces can interact with negative parts of other molecules, and thus give rise to halogen bonding. The computed data are fully consistent with the experimental observation that potency increases in the order Cl<Br<I, with fluorine being inactive.

We have suggested the term " σ -hole" to denote the positive halogen surface region, because it is centered on the C–X axis and is surrounded by negative electrostatic potential (Figs. 2, 3, 4, 5, 6) [35]. Why are there σ -holes in some instances and not in others, and what determines how strongly positive they are?



Fig. 5 The computed B3PW91/6-31G(d,p) electrostatic potential, in kcal mol⁻¹, on the 0.001 electrons/bohr³ surface of CF₃Br. The bromine atom is *pointing out of the page*. The color ranges are: *red*, more positive than 15; *yellow*, between 7 and 15; *green*, between 0 and 7; *blue*, between -10 and 0; *purple*, more negative than -10



Fig. 6 The computed B3PW91/6-31G(d,p) electrostatic potential, in kcal mol⁻¹, on the 0.001 electrons/bohr³ surface of O_2N -CH₂CH₂-Cl. The chlorine atom is at the *left*. The color ranges are: *red*, more positive than 15; *yellow*, between 7 and 15; *green*, between 0 and 7; *blue*, between -10 and 0; *purple*, more negative than -10

These questions were addressed in a natural bond order (NBO) analysis of the molecules CF_3X , where X=F, Cl, Br and I [35]. Two factors emerged: the electronegativity of the halogen and the extent of *sp* hybridization of its unshared *s* valence electrons.

For chlorine, bromine and iodine, the formation of the F_3C-X bond was found to involve essentially the half-filled p orbital of each; sp hybridization is minimal, with s-contributions of only 12% for Cl, 9% for Br and 9% for I. Similarly, the s unshared electrons of these atoms show very little p character: 12%, 8% and 8%, respectively. Thus the three unshared pairs of each of these halogens closely approximate the configuration $s^2 p_x^2 p_y^2$, where p_x and p_y are perpendicular to the C–X axis. These six electrons create a belt of negative electrostatic potential around the central portion of the halogen atom. Only its outermost region, the σ -hole, retains the positive potential characteristic of the

Table 1 Most positive electro-
static potentials, $V_{S,max}$, on
the 0.001 electrons/bohr³surfaces of halogens X in
molecules RX

All are located at intersections of surfaces with R-X axes. Values are in kcal mol⁻¹. The calculations were at the B3PW91/6-31G(d,p) level.

RX	V _{S,max}
H ₃ C–Cl	-1.5
H ₂ FC-Cl	3.5
HF ₂ C-Cl	8.9
F ₃ C-Cl	16.3
H ₃ C–Br	5.9
F ₃ C–Br	21.3
H–C≡C–Cl	20.6
NC–C≡C–Cl	34.7
HO-CH ₂ CH ₂ -Cl	-1.1
HO-CH ₂ CH ₂ -Br	5.9
O2N-CH2CH2-Cl	7.8
O2N-CH2CH2-Br	14.8
Cl ₂	23.8
Br ₂	29.1

free, spherically-symmetric atom [28, 29] (in which each p orbital has just 5/3 electrons). This picture accordingly accounts for the observed preference of electrophiles to interact laterally with the halogen, and nucleophiles linearly.

How does fluorine differ from this picture? First, there is significant *sp* hybridization; [36, 37] the orbital involved in the F₃C–F bond is 75% *p*, 25% *s*, while the unshared *s* electrons have 25% *p* character. The hybridization of the *s* electrons produces an influx of electronic charge into the outermost portion of the fluorine, where the σ -hole would be. Second, the high electronegativity of fluorine results in its having the major share of the F₃C–F bonding electrons, 75%, compared to about 50% for the other halogens in their respective F₃C–X bonds. This additional electronic charge further helps to neutralize the σ -hole.

Thus, the combined effects of *sp* hybridization and high electronegativity eliminate the σ -hole in the case of fluorine. Both factors diminish progressively in importance in proceeding to chlorine, bromine, and iodine. While our NBO analysis was limited to the CF₃X systems, we suggest that the factors that have been identified are more general, and can account for halogen bonding capacity increasing in the order Cl<Br<I (and apparently none for F).

In CH₃Cl, these factors are sufficiently significant to prevent the chlorine from having a σ -hole; however one develops as fluorines are substituted and offset the chlorine's inherent electronegativity (Table 1). For bromine and iodine, the σ -holes that do exist in CH₃Br and CH₃I are enhanced by the introduction of fluorines. In Cl_2 and Br_2 , the only issue is the degree of *sp* hybridization of the *s* unshared electrons, and this is evidently quite small since there are strong σ -holes (Table 1).

In the present context, it is relevant to mention reports of covalently-bonded halogens, in molecules RX, having shorter radii along the extended R–X axis than perpendicular to it [38–40]. This has been called "polar flattening", and is fully consistent with the preceding discussion; the $s^2 p_x^2 p_y^2$ configuration of unshared pairs produces a buildup of electronic charge around the central portion of the atom, the observed anisotropy.

Computational treatments of halogen bonding interactions

There have been several detailed computational analyses of halogen-bonded systems [40–42], which have examined the roles of electrostatics, dispersion, exchange–repulsion, charge–transfer, highest-occupied and lowest-unoccupied orbitals, etc. Some of the calculated interaction energies are listed in Table 2. In most instances, the interaction distance is also included.

The data in Table 2 bring out certain points, all of them in agreement with the discussion in Section 3:

(1) The effects of increasing the electron-withdrawing powers of the R portions of the molecules RX can be seen in the series $CH_xF_yI \cdot NH_3$ and $CH_xF_yCl NH_3$.

Table 2 Computed halogen Interaction energy Method System Interaction distance bond interaction energies (kcal mol^{-1}) and distances (A) -2.5 BP86/DZVP^a CH₃I · NH₃ I-N: 3.071 CH2FI · NH3 -3.2I-N: 3.040 CHF₂I · NH₃ -4.3I-N: 2.978 $CF_3I \cdot NH_3$ -6.4I-N: 2.882 $CF_3Br \cdot NH_3$ -4.7Br-N: 2.817 $CF_3Cl \cdot NH_3$ -2.3Cl-N: 2.900 BP(ZORA)^b $CF_3I \cdot N(CH_3)_3$ -5.64I-N: 2.883 $CF_3I \cdot P(CH_3)_3$ -5.76I-P: 3.195 $CF_3I \cdot S(CH_3)_2$ I-S: 3.259 -3.87CF₃I · ON(CH₃)₃ -7.81I-O: 2.768 CF₃I · OP(CH₃)₃ -3.94 I-O: 2.923 $CF_3I \cdot OS(CH_3)_2$ -3.32I-O: 2.908 B3PW91/6-31G(d,p)^c $CH_3Cl\cdot NH_3$ +0.1Cl-N: 3.450 CH₂FCl · NH₃ Cl-N: 3.326 -0.5CHF₂Cl · NH₃ -1.2Cl-N: 3.144 ^a Interaction energies include $CF_3Cl \cdot NH_3$ Cl-N: 3.094 -2.3corrections for basis set super-CH₂FCl · NH₃ B3PW91/6-311G(3df,2p)^c -1.4position error. Reference [41] CHF₂Cl · NH₃ -2.2Interaction energies include CF₃Cl · NH₃ -3.1corrections for basis set super- $CCSD/6 - 31 + G(d)^c$ CH₂FCl · NH₃ -1.1Cl-N: 3.243 position error. Reference [42] CHF₂Cl · NH₃ -2.1Cl-N: 3.140 ^c Present work. Zero-point and basis set superposition correc-CF₃Cl · NH₃ Cl-N: 3.041 -3.2tions not included.

As expected, increasing the number of fluorines leads to a more negative interaction energy and smaller separation.

- (2) The series CF₃X · NH₃, where X=Cl, Br and I, shows the strength of the halogen bonding to increase in the order Cl<Br<I.</p>
- (3) CH₃Cl does not form a stable complex with NH₃, nor (as shown by Lommerse et al. [40]) with CH₂O or NC-C≡C-Cl.

We are not aware of any experimental interaction energies for the systems in Table 2; however measured values for complexes **5** and **6**, -5.0 ± 0.1 kcal mol⁻¹ [43] and -7.4 kcal mol⁻¹ [44], respectively, are quite similar to the -6.4 kcal mol⁻¹ calculated for CF₃I \cdot NH₃ and -5.64 kcal mol⁻¹ for CF₃I \cdot N(CH₃)₃ (Table 2).



Importance of halogen bonding

The significance of halogen bonding in biological systems and processes has recently been surveyed by Auffinger et al. [34] and by Metrangolo et al. [45]. It occurs, for example, in ligand binding, recognition, conformational equilibria and molecular folding. For instance, a key factor in the recognition of thyroid hormones by their protein receptors is believed to be numerous short I---O contacts with carbonyl groups of amino acid residues. [34, 46] Some inhibitors have been found to function by the formation of halogen-bonded complexes; this emphasizes the potential of exploiting such interactions in drug design. An example is 4, 5, 6, 7-tetrabromobenzotriazole, which efficiently displaces charged ATP from its binding site on phospho-CDK2-cyclin A, primarily by means of Br-O interactions. [47] Halogen bonding has also been implicated in the actions of some anesthetics. [45]

Another important and intriguing application of halogen bonding is in crystal engineering. [45] This involves formulating cocrystals with specific desired features, such as the spatial orientations and/or separations of the components. Thus by combining α,ω -diiodoperfluoroalkanes, I-(CF₂)_n-I with 1,4-dicyanobutane, NC-(CH₂)₄-CN, and 1,6-dicyanohexane, NC-(CH₂)₆-CN, it is possible to produce chains with hydrocarbon and perfluorocarbon segments of variable lengths: [48]

----I-
$$(CF_2)_n$$
-I----NC- $(CH_2)_m$ -CN----I- $(CF_2)_n$ -I----NC- $(CH_2)_m$ -CN----

In 7, n is 2, 4, 6 or 8 and m is 4 or 6. Such approaches have been used, for example, to obtain materials with nonlinear optical activity, [49] or increased superconducting capacity [50].

Conclusions

Despite all of the work that has been mentioned and cited, it seems fair to say that halogen bonding is still relatively little recognized as a widely-occurring type of noncovalent interaction, certainly much less than hydrogen bonding. The concept that a covalently-bonded halogen atom could be at least weakly attracted to a negative site on another molecule may still seem unlikely to many researchers. Nevertheless, it is now well-established that this does occur, and we have sought in this paper to make this interaction plausible. Furthermore, as has been discussed at much greater length elsewhere, [34, 45] exploiting halogen bonding offers remarkable possibilities for designing and developing a whole array of compounds and materials, with applications ranging from drugs to electronics. To quote Metrangolo et al. [51], "The XB concept is still in its infancy." It should have an important future.

Acknowledgment We would like to express our gratitude to Professor Jaroslav Burda, who very kindly provided facilities at the Charles University in Prague so that we could prepare this paper while most of us were evacuees from Hurricane Katrina, which hit New Orleans on August 29, 2005.

References

- 1. Guthrie F (1863) J Chem Soc 16:239–244
- 2. Remsen I, Norris JF (1896) Am Chem J 18:90–96
- 3. Mulliken RS (1952) J Am Chem Soc 74:811-824
- 4. Flurry RL Jr (1969) J Phys Chem 69:1927-1933
- 5. Flurry RL Jr (1969) J Phys Chem 73:2111-2117
- 6. Bent HA (1968) Chem Rev 68:587-648
- 7. Hassel O (1970) Science 170:497-502
- 8. Dumas J-M, Peurichard H, Gomel MJ (1978) Chem Res (S) 54–57
- 9. Dumas J-M, Geron C, Peurichard H, Gomel M (1976) Bull Soc Chim Fr 720–722
- Dumas J-M, Kern M, Janier-Dubry JL (1976) Bull Soc Chim Fr 1785–1787
- 11. Murray-Rust P, Motherwell WDS (1979) J Am Chem Soc 101:4374–4376
- Murray-Rust P, Stallings WC, Monti CT, Preston RK, Glusker JP (1983) J Am Chem Soc 105:3206–3214

- Ramasubbu N, Parthasarathy R, Murray-Rust P (1986) J Am Chem Soc 108:4308–4314
- Bernard-Houplain M-C, Sandorfy C (1973) Can J Chem 51:1075– 1083
- Bernard-Houplain M-C, Sandorfy C (1973) Can J Chem 3640– 3647
- 16. Di Paolo T, Sandorfy C (1974) Chem Phys Lett 26:466-469
- 17. Di Paolo T, Sandorfy C (1974) Can J Chem 52:3612-3622
- Brinck T, Murray JS, Politzer P (1992) Int J Quantum Chem, Quantum Biol Symp 19:57–64
- Murray JS, Paulsen K, Politzer P (1994) Proc Indian Acad Sci, Chem Sci 106:267–275
- 20. Stewart RF (1972) J Chem Phys 57:1664-1668
- 21. Politzer P, Truhlar DG (eds) (1981) Chemical applications of atomic and molecular electrostatic potentials. Plenum, New York
- 22. Politzer P, Laurence PR, Jayasuriya K (1985) Environ Health Perspect 61:191–202
- 23. Murray JS, Politzer P (1998) J Mol Struct, Theochem 425:107-114
- 24. Politzer P, Murray JS (1999) Trends Chem Phys 7:157-165
- 25. Politzer P, Murray JS, Peralta-Inga Z (2001) Int J Quantum Chem 85:676–684
- 26. Bader RFW, Carroll MT, Cheeseman JR, Chang C (1987) J Am Chem Soc 109:7968–7979
- 27. Hagelin H, Brinck T, Berthelot M, Murray JS, Politzer P (1995) Can J Chem 73:483–488
- Weinstein H, Politzer P, Srebrenik S (1975) Theor Chim Acta 38:159–163
- 29. Politzer P, Murray JS (2002) Theor Chem Acc 108:134-142
- 30. Scrocco E, Tomasi J (1973) Top Curr Chem 42:95–170
- 31. Politzer P, Daiker KC (1981) In: Deb BM (ed) The force concept in chemistry (Ch 6). Van Nostrand, New York
- Politzer P, Murray JS (1991) In: Lipkowitz KB, Boyd DB (eds) Reviews in computational chemistry Ch 7 Vol 2. VCH, New York

- 33. Politzer P, Harris RR (1970) J Am Chem Soc 92:6451–6454 (and references cited)
- Auffinger P, Hays FA, Westhof E, Shing Ho P (2004) Proc Nat Acad Sci 101:16789–16794
- Clark T, Hennemann M, Murray JS, Politzer P (2006) J Mol Model DOI 10.1007/s00894-006-0130-2
- 36. Kutzelnigg W (1984) Angew Chem 96:262-269
- 37. Kutzelnigg W (1984) Angew Chem, Int Ed Engl 23:272-275
- Nyburg SC, Wong-Ng W (1979) Proc Roy Soc (London) A 367:29–45
- Price SL, Stone AJ, Lucas J, Rowland RS, Thornley AE (1994) J Am Chem Soc 116:4910–4918
- Lommerse JPM, Stone AJ, Taylor R, Allen FH (1996) J Am Chem Soc 118:3108–3116
- 41. Valerio G, Raos G, Meille SV, Metrangolo P, Resnati G (2000) J Phys Chem, A 104:1617–1620
- 42. Romaniello P, Lelj F (2002) J Phys Chem, A 106:9114-9119
- 43. Larsen DW, Allred AL (1965) J Phys Chem 69:2400-2401
- Corradi E, Meille SV, Messina MT, Metrangolo P, Resnati G (2000) Angew Chem, Int Ed Engl 39:1782–1786
- Metrangolo P, Neukirch H, Pilati T, Resnati G (2005) Acc Chem Res 38:386–395
- 46. Cody V, Murray-Rust P (1984) J Mol Struct 112:189-199
- 47. De Moliner E, Brown NR, Johnson LN (2003) Eur J Biochem 270:3174–3181
- Metrangolo P, Pilati T, Resnati G, Stevenazzi A (2003) Curr Opin Colloid Interface Sci 8:215–222
- Thallapally PK, Desiraju GR, Bagien-Bencher M, Masse R, Bourgogne C, Nicoud JF (2002) Chem Commun 1052–1053
- Imakubo T, Tajima N, Tamura M, Kato R, Nishio Y, Kajita K (2003) Synth Met 133–134:181–183. DOI 10.1007/s00894-006-0130-2
- 51. Metrangolo P, Neukirch H, Pilati T, Resnati G (2005) Acc Chem Res 38:393–394